New Method for Synthesis of Coatings of Molybdenum, Tungsten, Their Carbides and Composites

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Received November 30, 2012; revised January 6, 2013; accepted January 24, 2013

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ABSTRACT

In this paper we report, for the first time, a new approach for synthesis of high quality faceted microcrystalline coatings of molybdenum (Mo), tungsten (W), their carbides and composites. These studies are carried out using Hot Filament Chemical Vapor Deposition (HF-CVD) method wherein parent materials (Mo and/or W) are taken in the form of wires (~0.5 mm dia) and are heated to a high temperature (T_f ~ 1500 - 2000 C), in ambient of “oxygen (O_2) diluted hydrogen (H_2) gas”. Due to high filament temperature (T_f), a series of pyrolytic reactions take place. Firstly, the gasification of wire material (Mo and/or W) occurs in the form of its oxide. The oxide molecules reach the substrate which is kept underneath the filament assembly. Secondly, molecular hydrogen gets dissociated into atomic hydrogen and subsequently reaches the substrate to react with oxide molecules, finally leading to the precipitation of a pure metal. This method can also be used, in situ, to convert metallic coatings into their carbides and/or composites. The method offers many other attractive features, which can not be rendered by the conventional CVD/PVD methods. The results are discussed in terms of temperature induced “Red-ox” reactions.

Keywords: CVD Coatings; Pyrolysis; Ceramics; Refractories

1. Introduction

Since materials play a central role in different technologies, there has been a tremendous increase in the activity of “materials research”. In view of a new trend of “collapsing dimensions” in modern technologies, the subject of “materials coatings” has received a prime importance to form new materials. Novelty of these new materials refers to a multi-parametric restrictions on different physical/chemical properties, so as to be suitable in given type of application/s. To design and develop such special coatings, a major importance has also been to the methods of fabrication of such coatings. Over last few years, substantial research efforts have been and are being expended in this subject. Various types of newer physical/chemical methods have been devised for synthesis of coatings of various types. On one hand, some of these methods are now matured enough to routinely achieve the objective, while on the other hand newer methods/concepts are still being proposed to synthesize required types of materials coatings.

The refractory metals particularly molybdenum (Mo), tungsten (W) and also their compounds viz. carbides, oxides etc. form a special class of “materials “coatings. These coatings exhibit properties useful for many technological applications [1-3]. In view of their high melting points, these materials are thermally very stable and hence can be used for high temperature applications [4]. Because of high erosion resistance, these coatings are useful for protection against high-energy radiations [5]. The feature of high “chemical corrosion resistance” makes them useful in corrosion science. These materials coatings also exhibit lower diffusivities towards different atomic species. So coatings of these materials can be used as diffusion barriers [6,7] as well as thermal barriers [8]. The resistance to electro-migration phenomenon as well as appropriate electrical resistivities makes them useful for device technologies for fabrication of schottky barriers, interconnect lines and back contacts to solar cells etc. [9-11]. These materials also show enhanced “electron emission” and hence these are useful for developments of electron emission devices [12]. The higher values of modulus and hardness attract their applications in wear control in mechanical industry [13-16]. The oxides of these materials have applications for gas sensing
[17] as well as electro chromic devices [18,19].

Because of high melting points, however, conventional resistive evaporation method is not possible for the fabrication of coatings of these materials. The conventional CVD method and the sputtering method can be used but both these methods pose problems such as 1) requirement of hazardous organic precursors; 2) limitations on area of deposition; 3) limited growth rates; 4) complicated system set up etc. A need is, thus, felt to use newer methodology which could avoid these problems and yield easier and efficient fabrication of thicker, high quality coatings of these materials.

In this brief report, we describe for the first time, a simple and novel approach to synthesize high quality, faceted, micro-crystalline coatings of molybdenum (Mo), tungsten (W), their carbides and composites. This method is primarily based upon “Hot Filament Chemical Vapor Deposition (HF-CVD)” technique. This new method has many attractive features, which are not rendered by conventional CVD/PVD methods. The present method is 1) very simple and efficient; 2) it offers an easy control on different process parameters which could lead to a different morphological features of the resultant coatings; 3) since the method is based on HF-CVD technique, it requires a simple system set up. More importantly; 4) the method does not require use of any hazardous chemical precursors; 5) the method renders much larger growth rates (typically more than ~10 \( \mu \)m/hour or even higher) than those offered by conventional CVD/ PVD methods and hence; 6) it is possible to achieve much thicker coatings over practicable time scales. Finally; 7) the method is capable of obtaining coatings on much larger areas. In this paper, we have demonstrated that it is just a question of appropriately controlling the process parameters, to achieve all these objectives.

2. Experimental

The HF-CVD set up [20,21] used in the present studies has been indigenously designed and developed in our laboratory. It consists of a water cooled stainless steel chamber (size \( \sim 30 \text{ cm dia} \times 25 \text{ cm height} \)) having a number of ports to mount different accessory components such as high current feed throughs for filament heating, a gas mixing unit and input gas lines, the filament and the substrate holders along with controls for X-Y movement and rotational movement etc. The small pieces (typical size \( \sim 10 \text{ mm} \times 10 \text{ mm} \)) of \( \langle 100 \rangle \) and \( \langle 111 \rangle \) silicon (Si), high purity (99.99%) polycrystalline alumina (\( \alpha-\text{Al}_2\text{O}_3 \)), copper (Cu), tool steel (TS), stainless steel (SS) etc. are used as substrates. The samples are cleaned by using standard procedures and are used for deposition experiments. The pure (99.99%) gases such as oxygen (O\(_2\)) and/or methane (CH\(_4\)) are diluted in excess amount of hydrogen (H\(_2\)) and/or argon (Ar) gas and then flown over the heated filament assembly of molybdenum (Mo) and/or tungsten (W) wires. For the deposition of pure metal coating, the gas composition H\(_2\):O\(_2\) = 100:3 sccm is used. The filament temperatures are adjusted, using Pyrometer, over the range 1500°C - 2000°C by passing a suitable amount of current. The gas flow rates are controlled by using mass flow controllers (MFCs). The microprocessor based combination of “auto-throttle valve and a Capacitance diaphram gauge” is used to control the chamber pressure. It is typically adjusted over the range 20 - 100 Torr depending upon the particular type of experiment. The deposition time is varied over 10 min - 120 min. Subsequent to deposition, the specimens are characterized by using methods such as conventional and glancing angle X-ray diffraction (XRD), field emission scanning electron microscopy (FE-SEM), energy dispersive analysis of X-rays (EDX), Resistivity measurements etc. to get an information on morphological, structural, and compositional features of resultant coatings. The studies using additional microscopic characterization tools such as transmission electron microscopy (TEM), atomic force microscopy (AFM), scanning tunneling Microscopy (STM), X-ray photo-electron spectroscopy (XPS), nanoindentation are also in progress in our laboratory and these results will be published separately.

3. Results and Discussion

In a given deposition experiment, the different types of substrates are kept “side-by-side” on the substrate holder so that these get processed at almost identical processing conditions. So it is meaningful to compare the morphologies of coatings, on different types of substrates.

**Figure 1** shows the FE-SEM micrographs, at different magnifications, corresponding to coatings obtained using Mo-filament (**Figures 1(a) and (b)**) and using W-filament (**Figures 1(c) and (d)**) on \( \langle 111 \rangle \) silicon substrates. These coatings are obtained using nominally adjusted process parameters, viz. the composition of gas mixture H\(_2\):O\(_2\) = 100:10 sccm, flow rate of gas mixture \( \sim 110 \text{ sccm} \), the filament temperature (\( T_f \)) = 1800°C, the substrate temperature (\( T_s \)) = 500°C, the chamber pressure = 30 Torr, and the deposition time 20 min. As can be seen from these micrographs, both the types of coatings exhibit a cauliflower type of morphology. The EDX and glancing angle X-ray diffraction measurements are also carried out on both these types of coatings. These results exhibit similar results in the context of structural and compositional features. The EDX measurements, as shown in **Figure 1(e)**, refers to the Mo-coatings which reveals that the coating consists of \( \sim 30 \% \) of oxygen and \( \sim 70 \% \) of molybdenum. While the glancing angle X-ray diffraction result, as shown in **Figure 1(f)**, for coating obtained using W-filament reveals formation of highly disordered (very broad
diffraction peaks) WO$_{3-x}$, α-tungsten and β-tungsten phases [22].

To achieve high quality coatings, the filament temperature (T$_f$) was increased to 1900°C, the substrate temperature (T$_s$) was also increased to ~800°C, the composition of gas used H$_2$:O$_2$ = 100:2 sccm. The chamber pressure and deposition time kept unaltered (30 Torr and 20 min, respectively, but these can also be changed. The variation of these parameters results in variation in the thickness of the film only). These happen to be the optimized conditions for getting high quality, faceted coatings of Mo and W on Si (Figure 2) and on Alumina substrates (Figure 3). As can be seen from the SEM overview micrographs, the coverage of Mo-coating (shown in Figure 2(a)) and W-coating (shown in Figure 2(c)) is very uniform throughout the sample area. The magnified FE-SEM views are shown in Figure 2(b) (for Mo coating) and Figure 2(d) (for W coating). These results reveal that in both the cases the particles are very well faceted, although, there is a difference in the morphology. The Mo-particles are of “hexagonal” shaped while W-particles are mainly of “three and four sided pyramidal shapes”. This seems to be very interesting because in both the cases we have <111> Si substrate and both metals (Mo and W) have cubic BCC-type lattice with almost the same lattice parameters (3.14 Å for Mo and 3.16 Å for W). This morphological difference remains the same even in the case of Alumina substrate (FE-SEM results are shown in Figure 3). There is also a difference in the particle size-distribution. In Mo-case there is almost no size-distribution (uniform particle size of ~0.8 μm) while for W-case the particle size varies over ~0.3 μm to 0.9 μm. The adhesion of coatings found is to be excellent as qualitatively tested by “Scoch-tape method”. Figures 2(e) and (f) show cross-sectional SEM micrographs for Mo-coating and W-coating, respectively. In both the cases, the growth of coatings is found to be of columnar type. This is in agreement with the results obtained earlier [9]. The thickness of Mo-coating is (~3 μm) found little larger than that of W coating is (~2 μm). This indicates that the growth rates are substantially high, due to which one could get very thick coatings over practicable deposition time scales, while maintaining high crystalline quality, uniformity, purity, good adhesion and reproducibility. All these features have been observed for the first time in the present studies, and would not have been possible with any other synthesis method. In the case of Alumina substrates, we got very similar results. Figure 3(a) shows FE-SEM result for virgin polycrystalline Alumina substrate. It consists of grains of size ~2 μm. For nominally adjusted process parameters (as described earlier, in the case of Si substrates) one gets a cauliflower-type morphology with
substantial amount of oxygen content (~30 - 40 at %) (in both cases, when Mo- or W-filaments are used). The compositional and structural features of such coatings are found to be very similar to those observed in case of Si-substrates. A typical coating morphology using Mo-filaments is shown in the SEM micrographs, at different magnifications, in Figures 3(b) and (c), as an example. Subsequent to the optimization of process parameters (as discussed earlier in the case of Si substrate) one gets high quality coatings of pure-Mo and pure-W. The typical results are shown in SEM micrographs of Figure 3(d) for Mo-coating and Figures 3(e) and (f), at different magnifications, for W-coatings. As can be seen, these coatings exhibit similar features to those obtained on Si-substrates, viz. 1) Uniform coverage of coatings throughout the area of the substrate; 2) The coatings are very well faceted; 3) The particles are of hexagonal shaped in case of Mo-coating while triangular shaped in the case of W-coating; 4) The particle size, however, is smaller than that observed for Si substrate, and in both the cases (Mo and W) there is very narrow size distribution. (Note that in the case W coating on Si substrate, a substantial size distribution was observed).

Figure 3. FE-SEM micrographs, at different magnifications, for Mo- and W-coatings on alumina substrates (a) virgin alumina substrate; (b) and (c) for Mo-coatings with nominally adjusted conditions; (d) high quality Mo-coating; (e) and (f) views for high quality of W-coating.

The typical EDX measurements and the glancing angle XRD on high quality coatings are depicted in Figure 4(a) for Mo-coating on Si substrate and in Figure 4(b) for W-coating on Alumina substrate. The EDX results exhibit strong signals due to Mo and W in the respective cases. Note that the oxygen signal in Figure 4(b) is due to underlying Alumina substrate and not from the overlayer W coating. We have confirmed this by carrying out EDX measurements on both types (Mo and W) of thicker coatings on Alumina substrates. In both cases, we have not observed any signal due to oxygen or any other impurity. This confirms the purity of coatings. The glancing angle (incident angle \( \theta \sim 3^\circ \)) X-ray diffraction pattern of Mo coating on Si substrate is shown in Figure 4(c). It shows well defined diffraction peaks at \( 2\theta = 40.5^\circ \) (\( d = 2.22 \) Å), 58.6° (\( d = 1.57 \) Å) and 73.6° (\( d = 1.28 \) Å) corresponding to BCC structure of Mo with lattice constant \( a = 3.14 \) Å [22]. These peaks correspond to <110>, <200> and <211> planes, respectively. Since both Mo and W has same BCC crystal structure with almost identical lattice parameter (Mo-3.14 Å, W-3.16 Å) their X-ray diffraction patterns happen to have very little difference in the peak positions. The X-ray diffraction result for W-coating on Alumina substrate is shown in Figure 4(d) which reveals well defined diffraction peaks at \( 2\theta = 40.26^\circ \) (\( d = 2.238 \) Å), 57.27° (\( d = 1.58 \) Å) and 73.2° (\( d =1.29 \) Å) due, re-
respectively, to the \(<110\), \(<200\> and \(211\>> crystallographic planes of crystalline body-centered cubic (\(\alpha\)-W) phase [22]. The small peaks labeled by “S” are due to alumina (\(\alpha\)-\(\text{Al}_2\text{O}_3\)) substrate. Yet another important facet of the present method refers to the fabrication of composite coating. Figure 5 shows typical results for synthesis of thicker (deposition time ~40 min) coating of Mo-W composite on Si substrate.

In these studies, the W and Mo filaments are used simultaneously (and alternately). The SEM micrographs, at different magnifications, are shown in Figure 5(a) and (b). From the overview micrograph of Figure 5(a), it is observed that the coating is very uniform over the whole area of the substrate. The magnified view in Figure 5(b) reveals faceted particles. Each particle exhibits a mixture of hexagonal and square faces indicating simultaneous growth of Mo and W lattice. The EDX measurements, shown Figure 5(c), reveal strong contributions due to Mo and W with no signal from substrate (since coating is thicker) and composition to be \(~\text{W}_{13}\text{Mo}_{87}\). Since both Mo and W have same BCC crystal structure with almost identical lattice parameter (Mo—3.14 Å, W—3.16 Å), it is expected that one would get infinite solid solubility [22]. The SEM result, however, indicates that both the metals grow separately within a given particle. So one gets a mixture of individual Mo and W particles, rather than each particle being a mixture of Mo and W. The X-ray diffraction patterns happen to be very similar to that of the individual pure metals and giving peaks at \(2\theta \sim 40.5^\circ\) (d ~ 2.22 Å), 58 (d ~ 1.57 Å), and 73.5 (d ~ 1.28 Å) corresponding to diffraction from \(\langle110\>, \langle200\> and \langle211\> planes [22]. Note that the XRD data for Mo-W composite is not available. It is also possible to change the composition of the resulting coatings by changing the number of each type of filaments. This methodology leads to the change in the total surface area exposed by each type of the filament, hence the difference in the amount of formation and sublimation of respective oxides, thus ultimately rendering different elemental compositions in the coating.

The coatings can be fabricated on larger areas also, just by giving a relative motion to the filament and the substrate holders. (e.g. X-Y motion for larger planner area, rotational motion for cylindrical substrates, linear motion for long strip/foil shaped substrate such as a “roll to roll” mechanism). In the present studies, we could get uniform depositions on over planer area of \(~\text{100 cm}^2\), and also on the rods having size 1 cm dia \(\times 3\) cm length. This kind of feature is not possible in conventional CVD/PVD methods, and thus, it forms yet another important aspect of the present method.

One more interesting feature of the present method refers to an “in situ” conversion of metal films in to its compounds such as a carbide, for example. After deposition of Mo or W coatings, the flow of oxygen gas in the chamber is stopped and the methane (CH\(_4\)) gas was introduced at flow rate of 5 - 10 sccm, keeping the hydrogen flow rate fixed at 100 sccm. The chamber pressure was also kept unaltered, i.e. at 30 Torr. The carburization time depends upon the thickness of the metal film (although it is a little larger than that used for deposition of the pure metal coating). The SEM result after carburization (~ for 30 min.) of W-coating (deposited for 20 min.) is shown in Figure 6(a). There is a little enhancement in the size of crystallites. The shape of particles is also changed to some extent although these are still faceted. The EDX result corresponding to carburization of Mo coating is shown in Figure 6(b), which now reveals a carbon contribution along with Mo (and Si from the substrate). The carbon percentage found to be ~35 at %, indicating formation of Mo\(_2\)C phase [22]. Similar results are observed in case of carburization of W-coating. The X-ray diffraction patterns after carburization of Mo and W are shown in Figures 6(c) and (d) respectively. In the former case, one gets prominent and sharp diffraction peaks (shown by solid circles) at \(2\theta = 34.4^\circ\) (d = 2.6 Å), 37.9° (d = 2.36 Å ) and 39.3° (d = 2.28 Å) 52.8° (d = 1.75), 72.4° (d = 1.3), 74.7° (d = 1.27) and 75.5° (d = 1.25) respectively due to \(\langle16,0,0\>, \langle002\>, \langle101\>, \langle102\>, \langle200\>, \langle112\> and \langle201\>> crystallographic planes of crystalline \(\alpha\)-Mo\(_2\)C (lattice constant a = 3.012 and c = 4.735) phase [22]. In the other case (carburization of W), one gets diffraction peaks (shown by solid circles) at \(2\theta\) values, viz. 31.5°, 35.6°, 48.3° and 73.0° corresponding to...
method. The approximate thumb rule calculations suggest that the carbon diffusivity (D) at the substrate temperature (T_s) ~ 800°C could be D ~ 10^{-11} \text{ cm}^2/\text{sec}, (indicating four orders of magnitude decrease from its value at T ~ 1500°C), in both cases [1].

We have also explored the utility of these (metal and their carbidies) coatings. In the first of these kinds of studies, we used these coatings as a buffer layer for fabrication of CVD-diamond coatings on copper, tool steel and stainless steel substrates. In all these cases, one gets problems in the deposition of CVD diamond. In case of copper one gets a quality growth of CVD diamond but due to very weak or no reaction at Cu-Diamond interface, the diamond coatings peel-off (due to incorporation of excessive compressive stresses due to difference in thermal expansion coefficients [23] of Cu and Diamond. In cases of iron based or Nickel based substrates such as Stainless Steel (SS), tool steel, Haste alloy etc. due to catalytic activity [20,23-27] of transition elements in the substrate, the precipitation and growth of graphitic/disordered carbon phases are favoured instead of a diamond phase. If a buffer layer of W or Mo or their carbidies is used prior to diamond deposition, one can get high quality diamond coatings. Note that the CVD-diamond coating experiment is also \textit{in situ}. The adhesion of such diamond coatings was also found to have much better (as qualitatively tested by “Scotch tape” method) and did not peel-off. The use of carbidies layers are utilized for cutting tools (such as Taps and drills) for enhancing cutting efficiency. \textit{Figure 7(a)} shows typical SEM micrograph of the diamond coating with the buffer layer on copper.

\textit{Figure 7(b)} shows W coating on tool steel. \textit{Figure 7(c)} shows photograph of different cutting tools such as Taps, drill-bits, rimmer etc. coated by carbidies. In yet another preliminary study, we fabricated patterned W-carbide coatings on Alumina and used this pattern as a heating element.

Typical patterned W coating (thickness ~20 \textmu m) on Alumina is shown in \textit{Figure 7(d)}. With the input power~30 V/500 mA, one gets the temperature rise beyond 500°C, with no damage in the coating. The response time for such a temperature-rise happens to be very small, ~15 sec. More detailed studies in the context of such applications are in progress in our laboratory.

4. Conclusions

New, simple and novel method, using HF-CVD technique, has been presented for the first time to synthesize high quality coatings of Mo, W, their carbidies and composites on various types of substrates. The method is primarily based upon temperature induced “Red-ox reactions”. The small amount of oxygen in the chamber gas leads to oxidation of the heated filaments. The oxide molecules reach the substrate via sublimation process. These molecules then undergo reduction process to render
precipitation of the pure metal. It was necessary to optimize the processing conditions to get high quality coatings. The growth of coatings is found to be of columnar type and adhesion found to be excellent. The method offers many attractive features not rendered by conventional CVD/PVD methods. Importantly, these include 1) non-requirement of any hazardous precursors; 2) high growth rates; 3) compatibility to obtain coatings on larger areas. The present studies reveal that amongst different process parameters, the filament temperature ($T_f$) and the composition of chamber gas are of more importance, which sensitively affect the nature of morphology and thickness of the resulting coatings. The morphological details of coating depend upon the type of the substrate. The growth of Mo particles is found to be of hexagonal shaped, while growth of W particles is found to have three/four sided pyramidal (or triangular) shaped geometries. In situ carburization of pure metal coatings leads to the formation of carbides (WC or Mo$_2$C phases). The Composites of Mo-W could also be fabricated by simultaneous use of both types of filaments.

5. Acknowledgements

The present studies are carried out under funding from BCUD, University of Pune and the UGC-CAS programme, Department of Physics, University of Pune. RVG is grateful for the fellowship from CNQS, Department of Physics, University of Pune. Help in experimentation from G. Deokar, M. Mujawar and Dr. B. Kale (from CMET, Pune) is also gratefully acknowledged.

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Copyright © 2013 SciRes.
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doi:10.1002/adfm.200801171


doi:10.1016/S0921-5107(98)00430-9

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doi:10.1063/1.351380